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# Orientation, Pattern Center Refinement and Deformation State Extraction through Global Optimization Algorithms

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## **Electron Backscatter Diffraction**

Electron backscatter diffraction is a fully automated SEM-based characterization technique to extract structural information from materials to study their microstructure, texture, defect density, residual strain, etc.



Zhu et al, Microscopy and Microanalysis, 2019

# **The Pattern Matching Problem**

Forward model (f) describing the accurate diffraction physics:

I<sub>simulated</sub>=f (keV, phase, geometry, orientation, pattern center, elastic deformation)

Known Partially known Unknown



How do we improve the similarity between  $I_{simulated}$  and  $I_{experimental}$ ?

- Realistic forward model (f)
- Improve the accuracy of orientation and PC
- Determine the elastic deformation tensor



# **Dynamical Simulation of EBSD Pattern: Forward Model**



Ground truth: Ni @ 30keV

**Deterministic part**: dynamical scattering model uses scattering matrix to predict probability of BSE distribution.

**Stochastic part**: Monte Carlo electron trajectory simulation to predict spatial and energy distributions for BSEs.

**Geometric part**: geometrical parameters-detector tilt, sample tile, crystal orientation, pattern center, deformation tensor.

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Callahan and De Graef, Microscopy and Microanalysis, 2013

## **Approximate Model for Deformation Tensor Inclusion**

$$(X,Y)_{L} = \ell(F^{-1}(L_{q}[p]))$$



**Approximate Deformation Model** 

#### **Rotated and Undeformed Pattern Coordinates:**

$$(X,Y)_L = \mathcal{L}(L_q[\widehat{\boldsymbol{p}}])$$

 $\hat{p}$ : detector pixel coordinates  $L_q$ :quaternion rotation operator q: (passive) rotation required to rotation  $\mathcal{L}$ : square Lambert transformation.

#### **Rotated and Deformed Pattern Coordinates:**

$$(X,Y)_L' = \mathcal{L}(F^{-1}(L_q[\widehat{\boldsymbol{p}}]))$$

 $F^{-1}$ : interpolation on the undeformed master



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# **Formulation of the Optimization Problem**

Definition of an optimization problem:

 $\max_{x \in S} \operatorname{sim} (f(\mathbf{x}), I_{experimental})$ 

seek for a minimizer  $x^*$  that gives best match with the experimental pattern: sim (f( $x^*$ ),  $|_{experimental}$ )  $\geq$  sim (f(x),  $|_{experimental}$ )

#### **Bounded optimization problem:**

Initial estimate: orientation=( $\varphi_1$ ,  $\Phi$ ,  $\varphi_2$ ), PC=(PCx, PCy, DD)

Optimized values: orientation\*= $(\varphi_1, \Phi, \varphi_2) \cdot s$ , PC \* =(PCx, PCy, DD) +pc

What about deformation?

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sim: similarity metric; x: n-dimensional parameter vector; S: subset of  $\mathbb{R}^n$ 

## **Formulation of the Optimization Problem**

Elastic deformation tensor contains the rotation and stretch:

Optimized values : PC\*=(PCx, PCy, DD) +pc

Elastic deformation tensor (8 degrees of freedom):

$$F = I + \begin{pmatrix} \Delta \beta_{11} & \beta_{12} & \beta_{13} \\ \beta_{21} & \Delta \beta_{22} & \beta_{23} \\ \beta_{31} & \beta_{32} & 0 \end{pmatrix} + \frac{\beta_{33}I}{\text{EBSD insensitive to spherical strain}!!!$$

For isotropic elastic material ( $\sigma_{33} = 0$ ; orientation=[0,0,0]):

$$\beta_{33} = \frac{-\lambda(\Delta\beta_{11} + \Delta\beta_{22})}{3\lambda + 2G} \qquad \lambda = \frac{Ev}{(1+v)(1-2v)} \qquad G = \frac{E}{2(1+v)} \qquad \begin{array}{c} \text{Carnegie} \\ \text{Mellon} \\ \text{University} \end{array}$$

Hardin et al, Journal of Microscopy, 2015





Pang et al, Ultramicroscopy, 2019

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# **Sloppy Feature Scaling: Rotation Correction**

Singh et al, Journal of Applied Crystallography, 2017

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### **Population Based Global Optimization**



Wikipedia.com/ Tanaka et al, Ultramicroscopy, 2019

## **Differential Evolution Algorithm**

| Selection      | $\boldsymbol{x}_{i,g+1} = \begin{cases} \boldsymbol{u}_{i,g+1} & \text{if } f(\boldsymbol{u}_{i,g+1}) \leq f(\boldsymbol{x}_{i,g}) \\ \boldsymbol{x}_{i,g} & \text{otherwise} \end{cases}$ | Carnegie<br>Mellon<br>University |
|----------------|--|----------------------------------|
| Crossover      | $\boldsymbol{u}_{i,g+1} = u_{j,i,g+1} \begin{cases} v_{j,i,g+1} & if \ rand_j \leq C_r \ or \ j = j_{rand} \\ x_{j,i,g} & otherwise \end{cases}$   |                                  |
|                | $v_{i,g+1} = x_{best,g} + F(x_{r_1,g} + x_{r_2,g} - x_{r_3,g} - x_{r_4,g})$  | DE/ best /2                      |
|                | $v_{i,g+1} = x_{best,g} + F(x_{r_1,g} - x_{r_2,g})$  | DE/best/1                        |
|                | $v_{i,g+1} = x_{i,g} + F(x_{best,g} - x_{i,g} + x_{1,g} - x_{r_2,g})$  | DE/rand-to-best/1                |
|                | $\boldsymbol{v}_{i,g+1} = \boldsymbol{x}_{r_1,g} + \boldsymbol{F}(\boldsymbol{x}_{r_2,g} + \boldsymbol{x}_{r_3,g} - \boldsymbol{x}_{r_4,g} - \boldsymbol{x}_{r_5,g})$                      | DE/rand/2                        |
| Mutation       | $v_{i,g+1} = x_{r_1,g} + F(x_{r_2,g} - \mathbf{x}_{r_3,g})$  | DE/rand/1                        |
| Initialization | $x_{i,g} = x_{j,i,g}$ $j \in \{1,, D\}, i \in \{1,, N_p\}, g \in \{1,, g_{max}\}$  | .}                               |

R. Storn, K. Price, Journal of Global Optimization, 1997

# **Hyperparameter Tuning**

- Crossover probability (C<sub>r</sub>): 0.7-0.9 (default:0.9)
- Mutation factor (F): 0.2-0.5 (default:0.5)
- Number of generations  $(g_{max})$ : 50-100 (default:100)
- Initial Population size (N<sub>p</sub>): 10D

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Zhu et al, Ultramicroscopy, 2021 (Under review)



**Mutation Schemes** 

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#### **Noise sensitivity**

#### $g_{max}$ =100, Np=60, Cr=0.9 and F = 0.5 (DE/rand/1)



Zhu et al, Ultramicroscopy, 2021 (Under review)



### **Hybrid Optimization: DE+NMS**

Zhu et al, Ultramicroscopy, 2021 (Under review)





Zhu et al, Ultramicroscopy, 2021 (Under review)

### **Deformation Tensor Inference: Simulated Patterns**



#### Absolute Strain Mapping with Any Reference Pattern

- 1. Pattern pre-processing: adaptive histogram equalization, high-pass/low-pass filter
- 2. Determine the reference pattern to be used and optimize its PC and orientation
- 3. Use optimized PC and determine the strain tensor of reference pattern
- 4. Use cross-correlation based HR-EBSD to determine the strain map relative to reference
- 5. Strain state correction based on strain state of the reference pattern

Zhu et al, Ultramicroscopy, 2021 (Under review)

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#### **Experimental Pattern Pre-Processing**



Zhu et al, Ultramicroscopy, 2021 (Under review)

#### **Experimental Validation: Low Cycle Fatigued TRIP Steel**



Zhu et al, Ultramicroscopy, 2021 (Under review)

# Summary

• The differential evolution algorithm outperforms particle swarm algorithm due to the nature of mutation.

• The search space for differential evolution is feasible up to  $\pm 20$  disorientation and  $\pm 10$  % detector width.

• Simulated undeformed patterns demonstrate an accuracy of ~0.04° for orientation and ~0.02% detector width for pattern center.

• Noisy simulated deformed patterns reveal an accuracy of shear strain and rotation components ~0.001 and ~0.002 for the normal strain.



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Github Link: https://github.com/EMsoft-org/EMsoft

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